

Development of Materials Processing Methods: Cathodic Vacuum Arc and Plasma Immersion Ion Implantation Combined

Tuesday, 11 November 2003 14:00 (1:00)

Content

Summary

Primary author(s) : M. BILEK (University of Sydney, Applied and Plasma Physics Group, Australia)

Presenter(s) : M. BILEK (University of Sydney, Applied and Plasma Physics Group, Australia)

Session Classification : Development of Materials Processing Methods: Cathodic Vacuum Arc and Plasma Immersion Ion Implantation Combined